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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09/916,682	07/30/2001	Yasutaka Ito	110580.01	9838
25944 7:	590 05/04/2005		EXAM	INER
OLIFF & BERRIDGE, PLC			PAIK, SANG YEOP	
P.O. BOX 1992 ALEXANDRIA	- ·		ART UNIT	PAPER NUMBER
			3742	
			DATE MAILED: 05/04/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)			
<b>-</b>	09/916,682	ITO, YASUTAKA			
Office Action Summary	Examiner	Art Unit			
	Sang Y Paik	3742			
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet wi	th the correspondence address			
A SHORTENED STATUTORY PERIOD FOR REATHE MAILING DATE OF THIS COMMUNICATION  - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reflection of the following specified above, the maximum statutory perions to reply within the set or extended period for reply will, by stated any reply received by the Office later than three months after the material patent term adjustment. See 37 CFR 1.704(b).	N. 1.136(a). In no event, however, may a re reply within the statutory minimum of thirt iod will apply and will expire SIX (6) MON tute, cause the application to become AB.	eply be timely filed y (30) days will be considered timely. THS from the mailing date of this communication. ANDONED (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 03	3 February 2005.				
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closed in accordance with the practice unde	•				
Disposition of Claims					
4)⊠ Claim(s) <u>9,10,12-17 and 19-24</u> is/are pendir	ng in the application				
4a) Of the above claim(s) is/are withd					
5) Claim(s) is/are allowed.	nami nom oondaarandi.				
6) Claim(s) 9,10,12-17 and 19-24 is/are rejected	ed.				
7) Claim(s) is/are objected to.					
8) Claim(s) are subject to restriction and	d/or election requirement.				
Application Papers					
9) The specification is objected to by the Exami	iner.				
10)☐ The drawing(s) filed on is/are: a)☐ a		by the Examiner.			
Applicant may not request that any objection to the					
Replacement drawing sheet(s) including the corr	ection is required if the drawing(	s) is objected to. See 37 CFR 1.121(d).			
11) The oath or declaration is objected to by the	= *				
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for forei	ian priority under 35 H.S.C. &	119(a)-(d) or (f)			
a) ☐ All b) ☐ Some * c) ☐ None of:	gir priority under 55 O.S.C. §	119(a)-(u) 01 (1).			
1.☐ Certified copies of the priority docume	ents have been received	•			
2. Certified copies of the priority docume		onlication No			
3.☐ Copies of the certified copies of the p					
application from the International Bure		reserved in this National Stage			
* See the attached detailed Office action for a li	, ,,,	received			
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Attachment(s)      Notice of References Cited (PTO-892)	A) I Imtamiliani O	ummary (PTO-413)			
2) Notice of Praftsperson's Patent Drawing Review (PTO-948)		ummary (P10-413) )/Mail Date			
B) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/0		formal Patent Application (PTO-152)			
Paper No(s)/Mail Date	6) 🔲 Other:	<b>-</b> ·			

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## **DETAILED ACTION**

## Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 9, 12-16 and 19-24 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yoshida et al (US 6,080,970) or Arami et al (US 5,904,872) in view of Koontz (US 5,877,473).

Yoshida or Arami discloses the sintered ceramic heater claimed including a disk-shaped ceramic substrate with a heat-generating pattern embedded therein, having a combination of spiral and bending pattern, disposed in the outer region of the ceramic substrate, a semiconductor wafer heated on the surface opposite to the surface of the ceramic substrate. Arami further shows that the disk-shaped ceramic substrate has the diameter of 8 inches or larger to accommodate a wafer having a diameter of 8 inches or 203 mm. Yoshida or Arami teaches that the ceramic substrate can be made of aluminum nitride. However, Yoshida and Arami do not show that the bending portion describes an arc having a curvature radius within a range of 0.1 mm to 20 mm with the bending width in a range of 1 mm to 20 mm.

Koontz shows a heating pattern having a bending portion whose curvature radius from 8.8 mm which is within the claimed range to keep the width of heating element consistently equal. Koontz teaches that such curvature reduces cold and hot spots along the heating element.

In view of Koontz, it would have been obvious to one of ordinary skill in the art to adapt Yoshida or Arami with the claimed curvature bending to eliminate hot and cold spots and provide the width of the bending portion within the claimed range or any other range as long as the width is constant to have a consistent electrical resistivity to provide for an uniform heating across its heating surface.

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With respect to claims 14 and 21, it would have been obvious to one of ordinary skill in the art to modify the diameter of the ceramic substrate more than 300 mm or more since the size of the ceramic substrate would have been dependent upon the size of the wafer that is being heated by the ceramic substrate and to provide sufficient heating area to encompass the entire wafer area for uniform heating across the wafer.

3. Claims 10 and 17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yoshida et al or Arami et al in view of Koontz as applied to claims 9, 12-16 and 19-24 above, and further in view of Ito et al (US 6,072,162) or Furuya et al (US 6,084,215).

Yoshida or Arami in view of Koontz discloses the ceramic heater claimed except having through holes for inserting supporting pins.

Ito and Furuya show a wafer supporting heater having a plurality of through holes for inserting supporting pins to support a wafer. In view of Ito or Furuya, it would have bee obvious to one of ordinary skill in the art to adapt Yoshida or Arami, as modified by Koontz, with the through holes to provide the supporting pins so that the wafer can be conveniently moved to or from the ceramic substrate during the wafer treating process.

## Response to Arguments

4. Applicant's arguments filed 2/3/05 have been fully considered but they are not persuasive.

The applicant argues that Yoshida and Arami do not show the claimed bending portion and its width. In the office action, it is indicated by the examiner that neither Yoshida nor Arami shows that particular feature. Examiner does not contend that they do. For such claimed feature, Koontz has been applied. The applicant argues that since the claimed feature is used in an environment that is different from the claimed semiconductor industry, it would not have been obvious to combine with Yoshida and Arami. However, the applicant's argument is not deemed persuasive since the teachings of Koontz are in the same field of endeavor, which is in the field of electrical heating element which utilizes the electrically conductive film coated on an insulating substrate, and Koontz relates to the particular problem with which the applicant was concerned of, i.e., to maintain uniform heating power along the heating element. Particularly, Koontz shows the heating element having the curvature radii ranges from 8.8 mm (column 7, lines 63), and further shows that the width of the bending is maintained with a consistent same width. This is because if the width of the heating element were not maintained within the same width, it would change the electrical resistivity that would produce varying power. Since Koontz teaches the advantages or benefits pertinent to the problems with which the applicant was concerned of and since Koontz is in the same field of endeavor that relates to the electrical resistance heating element, it would have been obvious to one of ordinary skill in the art to modify Yoshida or Arami so that a more uniform heating can be maintained in its heating devices. Thus, the applicant's arguments are deemed unpersuasive.

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5. THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sang Y Paik whose telephone number is 571-272-4783. The examiner can normally be reached on M-F (9:00-4:00) First Friday Off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robin Evans can be reached on 571-272-4777. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Sang Y Paik
Primary Examiner
Art Unit 3742

syp